AMENDMENT UNDER 37 C.F.R § 1.116 **EXPEDITED PROSECUTION - ART GROUP 1795**

03500.518677 PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)		
SHOJI SHIBA, ET AL.	:	Examiner: Anca Eoff	
Application No.: 10/577,218	:	Group Art Unit: 1795	
Filed: April 26, 2006	:	Confirmation No.: 3411	
For: PHOTOSENSITIVE RESIN COMPOSITION, METHOD OF FORMING LEVEL DIFFERENCE PATTERN USING THE PHOTOSENSITIVE RESIN COMPOSITION, AND METHOD OF PRODUCING INK JET HEAD	:) :) :	Date: December 16, 2008	DO NOT ENTER: /A.E./
Commissioner for Patents P.O. Box 1450			12/22/2008

AMENDMENT AFTER FINAL REJECTION

Sir:

Introductory Comments: a)

Alexandria, VA 22313-1450

In response to the final Official Action dated September 18, 2008, kindly amend the above-identified application as follows.